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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/800,880	03/15/2004	Dingjun Wu	06457 USA	1949

23543 7590 09/26/2006

AIR PRODUCTS AND CHEMICALS, INC.  
PATENT DEPARTMENT  
7201 HAMILTON BOULEVARD  
ALLENTOWN, PA 181951501

EXAMINER
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STOUFFER, KELLY M

ART UNIT	PAPER NUMBER
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1762

DATE MAILED: 09/26/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

## Office Action Summary

**Application No.**

10/800,880

**Applicant(s)**

WU ET AL.

**Examiner**

Kelly Stouffer

**Art Unit**

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --  
**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

### Status

- 1) ☒ Responsive to communication(s) filed on 15 March 2004.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

### Disposition of Claims

- 4) ☒ Claim(s) 1-15 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-15 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

### Application Papers

- 9) ☒ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

### Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  
a) ☐ All b) ☐ Some \* c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
  - ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- \* See the attached detailed Office action for a list of the certified copies not received.

### Attachment(s)

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)  | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)   | 5) <input type="checkbox"/> Notice of Informal Patent Application                       |
| 3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08)<br>Paper No(s)/Mail Date <u>15 March 2004</u> . | 6) <input type="checkbox"/> Other: _____  |

## **DETAILED ACTION**

### ***Specification***

1. The following guidelines illustrate the preferred layout for the specification of a utility application. These guidelines are suggested for the applicant's use.

### **Arrangement of the Specification**

As provided in 37 CFR 1.77(b), the specification of a utility application should include the following sections in order. Each of the lettered items should appear in upper case, without underlining or bold type, as a section heading. If no text follows the section heading, the phrase "Not Applicable" should follow the section heading:

- (a) TITLE OF THE INVENTION.
- (b) CROSS-REFERENCE TO RELATED APPLICATIONS.
- (c) STATEMENT REGARDING FEDERALLY SPONSORED RESEARCH OR DEVELOPMENT.
- (d) THE NAMES OF THE PARTIES TO A JOINT RESEARCH AGREEMENT.
- (e) INCORPORATION-BY-REFERENCE OF MATERIAL SUBMITTED ON A COMPACT DISC.
- (f) BACKGROUND OF THE INVENTION.
  - (1) Field of the Invention.
  - (2) Description of Related Art including information disclosed under 37 CFR 1.97 and 1.98.
- (g) BRIEF SUMMARY OF THE INVENTION.
- (h) BRIEF DESCRIPTION OF THE SEVERAL VIEWS OF THE DRAWING(S).
- (i) DETAILED DESCRIPTION OF THE INVENTION.
- (j) CLAIM OR CLAIMS (commencing on a separate sheet).
- (k) ABSTRACT OF THE DISCLOSURE (commencing on a separate sheet).
- (l) SEQUENCE LISTING (See MPEP § 2424 and 37 CFR 1.821-1.825. A "Sequence Listing" is required on paper if the application discloses a nucleotide or amino acid sequence as defined in 37 CFR 1.821(a) and if the required "Sequence Listing" is not submitted as an electronic document on compact disc).

It is requested that the applicant include the heading BRIEF DESCRIPTION OF THE SEVERAL VIEWS OF THE DRAWING(S) with the phrase "Not Applicable" following the section heading.

2. The disclosure is objected to because of the following informalities:

On page 9 lines 1 from 10 should be --from 10--.

Appropriate correction is required.

***Claim Rejections - 35 USC § 112***

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

3. Claims 13 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 13 recites the limitation "the fluorine-containing reactive gas" in line 1 of the claim. There is insufficient antecedent basis for this limitation in the claim as claim 13 depends from claim 1 and there is no provision for a fluorine-containing reactive gas in claim 1.

4. Claims 2-7, 9-12, 14 and 15 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 2, 6, 9, 12, 14 and 15 are improper Markush claims as they do not use proper Markush language (group consisting of...and) or refer to the choices in the alternative. As written claims, 2, 6, 9, 12, 14 and 15 are indefinite because it is unclear if the applicant is claiming one of the group or the entire group in combination. Claims 3-5, 7 and 11 are rejected as being dependant upon rejected base claims.

***Claim Rejections - 35 USC § 103***

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

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5. Claims 1-4, 12 and 14-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over US Patent number 6554910 to Sandhu et al. in view of US Patent publication 2002/0071912 to Giolando.

Regarding claim 1, Sandhu et al. discloses a process used to clean a reactor used to coat substrates with titanium oxide combinations using metal source gases such as  $\text{TiCl}_4$  (column 1 lines 8-14, 22-40) that leave contaminant deposits on chamber walls that need cleaned off after deposition (columns 1-2 lines 41-14). The reactor to be cleaned contains a chamber comprising a surface at least partially coated with the metal residue (column 2 lines 33-40). A reactive gas, or treatment gas, is added to the chamber with a cleaning agent to interact with the residue to form a removable treatment product, (column 2 lines 33-40) which one of ordinary skill in the art would recognize as being volatile because this process takes place without opening the chamber and it would not be able to be removed otherwise. Sandhu et al. implies that the  $\text{TiCl}_4$  may be used to form titanium oxide during a CVD process on a surface, but does not explicitly state this. Giolando teaches a using  $\text{TiCl}_4$  during a CVD process to deposit titanium oxide as a procedure well known in the art that leaves  $\text{TiCl}_4$  deposits on the chamber surface (paragraph 0004 et seq.). One would want to use  $\text{TiCl}_4$  to deposit metal source materials for semiconductor applications (Sandhu et al. column 1 et seq.).

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Sandhu et al. to explicitly state that the  $\text{TiCl}_4$  is used to deposit titanium oxide as taught by Giolando in order to use a precursor well-known in the art to deposit metal source materials for semiconductor applications.

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With regard to claims 2-4, Sandhu et al. discloses the cleaning gas as chlorine ( $\text{Cl}_2$ ) or chlorine containing cleaning gases in column 5 lines 1-3.

Regarding claim 12, Sandhu et al. discloses an opening in the chamber 22 in Figure 1 that is for introducing the cleaning gas. It is obvious to one of ordinary skill in the art that such a cleaning gas (chlorine as used by Sandhu et al.) must come from a gas cylinder with a safe delivery system, otherwise the gas would escape to the atmosphere and would be poisonous.

With regard to claim 14, Giolando discloses the article receiving the titanium oxide film to be a glass substrate, or work piece at least as broadly recited by claim 14.

Regarding claim 15, Sandu et al. in view of Giolando et al. include all of the provisions of claim 15, as described above.

6. Claims 5-7, 9 and 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sandhu et al. in view of Giolando as applied above, and further in view of US Patent number 6635569 to Ameen et al. Sandhu et al. in view of Giolando is applied above but does not include a fluorine-containing gas as a precursor, but does include provisions for plasma in column 6 lines 10-12. Ameen et al. teaches the removal of  $\text{TiCl}_x$  precursors on a chamber walls using  $\text{NF}_3$  (as required by claims 5-7) or  $\text{Cl}_2$  (as taught by Sandhu et al.) as an in situ plasma (as required by claims 9-10) in column 9 lines 1-5. The fluorine-containing gas of Ameen et al. may be used with a reasonable expectation of success with the combined method of Sandhu et al. and Giolando in order to provide alternative cleaning gases (as implied by the document of Ameen et al. to clean deposited  $\text{TiCl}_4$  precursors from reactor surfaces (column 9 lines 1-5).

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Sandhu et al. and Giolando to include fluorine containing gases as cleaning gases as taught by Ameen et al. to clean deposited  $\text{TiCl}_4$  precursors from reactor surfaces.

7. Claims 11 and 13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sandhu et al. in view of Giolando as applied above, and further in view of Ameen et al. and US Patent number 5788778 to Shang et al. Sandhu et al. in view of Giolando and in further view of Ameen et al. is described above, but does not include the plasma generated from the cleaning gas as remote plasma. Shang et al. teaches using a remote plasma source to generate a cleaning plasma for cleaning the inside of a chamber (column 2 lines 34-56) because it is more efficient than using an in situ plasma source (column 1 lines 38-42). The remote plasma generator 46 of Shang et al. where the cleaning gas can said to be formed is in close proximity to the deposition chamber 10 as required by claim 13, at least as broadly recited by the claim.

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Sandhu et al., Giolando, and Shang et al. to include a remote plasma source for generating the cleaning plasma as taught by Shang et al. in order to perform a more efficient cleaning process.

8. Claim 8 is rejected under 35 U.S.C. 103(a) as being unpatentable over Sandhu et al. in view of Giolando as applied above, and further in view of Shang et al. Sandhu et al. and Giolando are described above and include all of the provisions of claim 8 except having an inert gas included in the cleaning gas. Shang et al. teaches including



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an inert gas in a cleaning gas to assist in the cleaning process or help initiate a cleaning plasma in a deposition chamber (column 5 lines 1-8).

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify Sandhu et al. and Giolando to include an inert carrier gas with the cleaning gas as taught by Shang et al. in order to assist in the cleaning process or help initiate a cleaning plasma in a deposition chamber.

### ***Conclusion***

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kelly Stouffer whose telephone number is (571) 272-2668. The examiner can normally be reached on Monday - Thursday 7:00-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy Meeks can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Kelly Stouffer  
Examiner  
Art Unit 1762

kms

  
TIMOTHY MEEKS  
SUPERVISORY PATENT EXAMINER